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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: **FUJITA, Kenichi**

Group Art Unit: 1773

Serial No.: **10/660,745**

Examiner: **Monique R. JACKSON**

Filed: **September 12, 2003**

P.T.O. Confirmation No.: **5996**

FOR: **HEAT RADIATION SHIELDING COMPONENT DISPERSION, PROCESS FOR ITS PREPARATION AND HEAT RADIATION SHIELDING FILM FORMING COATING LIQUID, HEAT RADIATION SHIELDING FILM AND HEAT RADIATION RESIN FORM WHICH ARE OBTAINED USING THE DISPERSION**

RESPONSE UNDER 37 CFR §1.116

**- EXPEDITED RESPONSE -
GROUP ART UNIT 1773**

DO NOT
ENTER
mj
9/26/06

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

August 28, 2006

Sir:

In response to the Office Action dated May 30, 2006, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.